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APPLICATION NO.		FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/853,217		05/11/2001	Douglas E. Weiss	55944USA9A.002	6357
32692	7590	02/13/2006		EXAMINER	
3M INNOV	<b>VATIVE</b>	PROPERTIES CO	TSOY, ELENA		
PO BOX 33- ST. PAUL,		133-3427		ART UNIT	PAPER NUMBER
SI. I AGE,	14114 33	155 5 127		1762	
				DATE MAILED: 02/13/2006	

Please find below and/or attached an Office communication concerning this application or proceeding.

				12				
-		Application No.	Applicant(s)					
		09/853,217	WEISS ET AL.					
	Office Action Summary	Examiner	Art Unit					
		Elena Tsoy	1762					
Period 1	The MAILING DATE of this communication app for Reply	pears on the cover sheet with the	correspondence address					
THE - Ext - If th - If N - Fai - Any	HORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. ensions of time may be available under the provisions of 37 CFR 1.13 or SIX (6) MONTHS from the mailing date of this communication. The period for reply specified above is less than thirty (30) days, a reply to period for reply is specified above, the maximum statutory period valure to reply within the set or extended period for reply will, by statute, or reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be ti y within the statutory minimum of thirty (30) da vill apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONI	mely filed ys will be considered timely. the mailing date of this communicat (ED) (35 U.S.C. § 133).	ion.				
1)[	Responsive to communication(s) filed on 06 J	lanuary 2006 .						
2a)⊠	This action is <b>FINAL</b> . 2b) ☐ Th	is action is non-final.						
3)	closed in accordance with the practice under			s is				
	tion of Claims	r e						
4)⊠	Claim(s) 1-15 and 18-22 is/are pending in the application.							
<b>-</b> \-	4a) Of the above claim(s) <u>18-22</u> is/are withdrawn from consideration.							
	Claim(s) is/are allowed.							
	Claim(s) 1-15 is/are rejected.							
	Claim(s) is/are objected to.	lootion i t						
•	Claim(s) are subject to restriction and/or tion Papers	r election requirement.						
	The specification is objected to by the Examine	r.						
·	The drawing(s) filed on is/are: a) ☐ accept		aminer.					
,	Applicant may not request that any objection to the	•						
11)	The proposed drawing correction filed on	_is: a)  approved b)  disappr	oved by the Examiner.					
	If approved, corrected drawings are required in rep	oly to this Office action.						
12)	The oath or declaration is objected to by the Ex	aminer.						
Priority	under 35 U.S.C. §§ 119 and 120							
13)	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a	a)-(d) or (f).					
а	)							
	1. Certified copies of the priority documents	s have been received.						
	2. Certified copies of the priority documents	s have been received in Applicat	ion No					
*	3. Copies of the certified copies of the prior application from the International Bur See the attached detailed Office action for a list	reau (PCT Rule 17.2(a)).	_					
14)	Acknowledgment is made of a claim for domestic	c priority under 35 U.S.C. § 119(	e) (to a provisional applica	ation).				
	<ul> <li>a) The translation of the foreign language pro Acknowledgment is made of a claim for domesti</li> </ul>	· ·						
Attachme	nt(s)							
2) 🔲 Not	ice of References Cited (PTO-892) ice of Draftsperson's Patent Drawing Review (PTO-948) rmation Disclosure Statement(s) (PTO-1449) Paper No(s)	5) Notice of Informal	y (PTO-413) Paper No(s) Patent Application (PTO-152)	<u>.</u> ·				

Application/Control Number: 09/853,217 Page 2

Art Unit: 1762

## Request for Reconsideration

Request for Reconsideration filed on 1/06/2006 has been entered. Claims 1-15, and 18-22 are pending in the application. Claims 18-22 are withdrawn from consideration as directed to a non-elected invention.

#### Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 1-15 stand rejected under 35 U.S.C. 103(a) as being unpatentable over Weiss et al (WO 00/04055) in view of Loda (US 4,163,172), Mukohyama et al (US 4,886,840) and Botman et al (Nuclear Instruments and Methods in Physics Research B 139) for the reasons of record set forth in paragraph 2 of the Office Action mailed on 10/03/2005.

### Response to Arguments

- 3. Applicants' arguments filed 1/06/2006 have been fully considered but they are not persuasive.
- (A) Applicants argue that none of the references cited by the Examiner describe providing a pulse rate greater than or equal to about 500 pulses per second. The Examiner has asserted that since total dose is a function of pulse frequency, dose per pulse and residence time it is not inventive to discover the optimum or workable ranges of result-effective variables by

routine experimentation. However, there is nothing in the cited references that would indicate that the devices for generating e-beams described therein would even have been capable of providing pulse frequencies greater than or equal to 500 Hz. For example, the upper range described by

Botman is 50 Hz, which is far below the 500 Hz recited in the present claims.

Page 3

The Examiner respectfully disagrees with this argument. The cited references show that the total dose is critical to achieve polymerization. Loda, Botman and Mukohyama et al teach that the total dose can be achieved using varying dose rate, e.g., 0.92 Gy to 75 Gy, residence time, and frequency. For example, Weiss et al teach that for some applications, the total dose of 100 kGy over residence time of greater than 1 second is required. As shown by Botman et al, for free radical polymerization of an acrylic monomer on seed latex, the total dose of 1700 Gy is required which can be achieved using pulses at dose per pulse of 0.92 Gy at pulse rate of 25 Hz (pulse per sec) (See page 493, paragraph 4.2, column 2) or pulses of 50 Hz and 3 Gy per pulse (See Abstract). Thus, the upper range of 50 Hz, described by Botman, is required to achieve the total dose of only 1700 Gy. Clearly, one of ordinary skill in the art at would easily recognize that to achieve the total dose of 100,000 Gy (100 kGy) for approximately the same residence time, much higher frequency, including over 500 Hz, should be used.

(B) Applicants assert that they have discovered that the manner in which the dose is delivered can have dramatic effect on the polymerization process itself: when the doge per pulse is relatively low (e.g., about 10 to about 90 Gy) and the pulse rate is below about 500 Hz, the reaction takes place predominantly in the <a href="https://example.com/homogeneous">homogeneous</a> mode because of the longer time, and the frequency of above 500 Hz, the <a href="https://example.com/heterogeneous">heterogeneous</a> mode of polymerization becomes more dominant. This surprising and unexpected discovery is not appreciated or otherwise disclosed anywhere in

Art Unit: 1762

the art of record. It is a totally new, highly efficient and unexpected way to achieve, for example, the advantage of <u>heterogeneous</u> mode of polymerization in a single phase system.

The Examiner respectfully disagrees with this argument. First of all, it was discussed above, that Loda teaches that polymerization is affected not only by the total dose of radiation, but also by the rate at which the dose is delivered: the high dose rate of very short electron beam pulses, of the order of microseconds (high frequency of more than 500), elicits chemical reactions, which may be different from those produced by the impact of long pulses or continuous radiation (See column 1, lines 53-60). Therefore, the fact that the manner in which the dose is delivered can have dramatic effect on the polymerization process itself was well known in the art.

(C) Applicants assert that the Examiner refers to Applicants' disclosure at page 2, lines 3-7 for the proposition that heterogeneous e-beam polymerization produces highly gelled polymers of adequate chain lengths between crosslinks. However, the Examiner overlooks the further assertion at page 2, lines 7-10 that three known methods of achieving heterogeneous polymerization include emulsion, solid phase catalysis, and precipitating conditions, and that all three of these methods involve phase separation to maintain the heterogeneous conditions. This is a totally new, highly efficient and unexpected way to achieve the advantage of heterogeneous polymerization in a single phase system. There is no precedence for this in the prior art, and therefore, the claimed invention is patentable over the cited references.

The Examiner respectfully disagrees with this argument for the following reasons:

(i) Weiss et al expressly teach that it is believed that, in contrast to prior art e-beam polymerization producing short-chain, branched, highly crosslinked polymeric structures (See page 3, lines 8-12), by conducting e-beam polymerization at temperatures below 20°C, the rate

Page 5

of polymer chain propagation is increasingly favored over the rate of termination, with the effect of producing polymers with a higher gel content and higher conversion (See page 11, lines 9-13) to provide the necessary balancing of viscous and elastic properties required for a pressuresensitive adhesive (See page 2, lines 3-10) by producing long-chain polymers with limited crosslinking over a broad range of coated thicknesses and with high conversion (See page 3, lines 21-25). As described in the Applicants' disclosure on page 2, lines 3-7, and page 6, lines 20-21), e-beam polymerization produces highly gelled polymers of adequate chain lengths between crosslinks over a broad range of coated thicknesses only when it is carried out heterogeneously in a single phase in contrast to homogeneous e-beam polymerization which produces short-chain, branched, highly crosslinked polymeric structures (See specification, page 4, lines 8-32). Therefore, e-beam polymerization of Weiss et al at temperatures below 20°C occurs heterogeneously in a single phase inherently.

(ii) As was discussed in the Office Action mailed on 2/14/2005, it would have been obvious to one of ordinary skill in the art to have determined the optimum values of the relevant dose per pulse parameters within a range of 0.92 Gy per pulse of Botman et al to 75 Gy per pulse of Mukohyama et al, pulses per second parameters including those within claimed range of 500-3,000 when used electron beams of 0.92 Gy per pulse of Botman et al to 75 Gy per pulse of Mukohyama et al and the optimum values of the relevant residence time parameters (including those of claimed invention) in Weiss et al through routine experimentation to provide the necessary balancing of viscous and elastic properties required for a pressure-sensitive adhesive by producing polymers having high molecular weight lengths between crosslinks. Since Weiss et al had chosen conditions of carrying out e-polymerization (e.g. temperatures below 20°C) to produce long-chain polymers with *limited* crosslinking over a broad range of coated thicknesses

Art Unit: 1762

and with high conversion and Loda teaches that e-polymerization is affected not only by the total dose of radiation, but also by the rate at which the dose is delivered: the high dose rate of very short electron beam pulses, of the order of microseconds (high frequency of more than 500), elicits chemical reactions, which may be different from those produced by the impact of long pulses or continuous radiation (See column 1, lines 53-60), the optimum values of the relevant dose/pulse and pulse rate Weiss et al in view of Loda, Botman et al and Mukohyama et al determined by routine experimentation would be within claimed ranges of low dose/pulse and high pulse rate in order to produce long-chain polymers with limited crosslinking.

(iii) According to Weiss et al, conducting e-beam polymerization at <u>temperatures below</u>

20°C and a predetermined total dose with <u>any mode</u> of applying e-beam, achieves long chain polymers and provides the necessary balancing of viscous and elastic properties required for a pressure-sensitive adhesive. Therefore, one of ordinary skill in the art would have reasonable expectation of success of achieving <u>at least</u> the same results in Weiss et al in view of Loda,

Botman et al and Mukohyama et al with *optimum* dose/pulse and pulse rate parameters.

#### Conclusion

4. THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37

Art Unit: 1762

CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event,

however, will the statutory period for reply expire later than SIX MONTHS from the mailing date

of this final action.

5. Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Elena Tsoy whose telephone number is 571-272-1429. The examiner can

normally be reached on Monday-Thursday, 9:00AM - 7:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor,

Timothy Meeks can be reached on 571-272-142323. The fax phone number for the organization

where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent

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system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Elena Tsoy Primary Examiner Art Unit 1762

February 7, 2006